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9-20-01
Harrison

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09/602,395
Filing Date June 22, 2000
Inventor Moore, J.
Assignee Micron Technology, Inc.
Group Art Unit 2813
Examiner Nguyen, T.
Attorney's Docket No. MI22-1384
Title: (As Amended) Methods of Forming Oxide Regions Over Semiconductor Substrates

RECEIVED

SEP 19 2001

TECHNOLOGY CENTER 2800

RESPONSE TO AUGUST 14, 2001 OFFICE ACTION

To: BOX NON-FEE AMENDMENT
Assistant Commissioner for Patents
Washington, D.C. 20231

From: Jennifer J. Taylor, Ph.D. (Tel. 509-624-4276; Fax 509-838-3424)
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AMENDMENTS

In the Specification

Please replace the Title with the following new Title:

--METHODS OF FORMING OXIDE REGIONS OVER SEMICONDUCTOR SUBSTRATES--

In the Claims

Cancel claims 17-28.

EL844047860
PAT-USIAM-MRG